Technical Subject:

Development of a Nanometer Microwave Imager

Corresponding Applicant:

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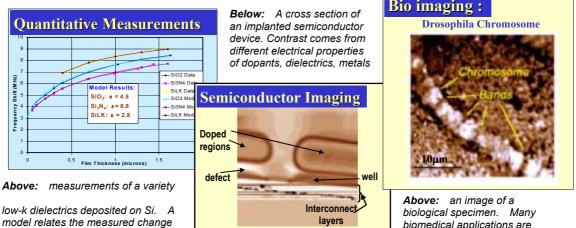
envisioned for the technology

The need:

Rapid submicron characterization of semiconductor devices, maps of protein distributions, and images of other microstructures are needed in many industries. The short-range forces involved in SPM systems make it difficult to rapidly scan the larger areas needed, or to operate with robust sensing tips that are not easily damaged.

Our Research:

Recently developed near-field microwave probes operate with a longer range force, and provide unique information about the electrical properties of a material^{1,2}. Some examples of measurements made in our laboratory with a current microwave probe:



50µm

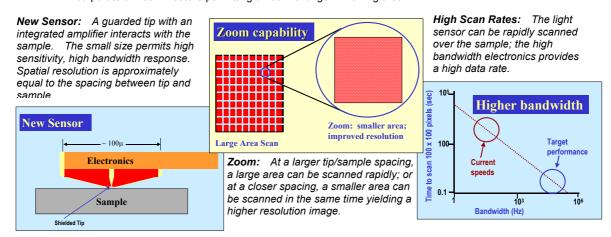
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model relates the measured change in the frequency of a resonant cavity to the dielectric constant

Our Proposal:

To develop a general-purpose imaging instrument, applicable to a wide range of applications, based upon current near-field microwave technology. Specific improvements to the current capabilities are the following:

- Develop a high sensitivity lightweight sensor with a protected tip
- Increase the scanning bandwidth so an image can be obtained in 1 -10 sec.
- Incorporate a "zoom" feature permitting a 100:1 change in viewing area



Invitation to collaborate: We would welcome colleagues interested in exploring applications for this new capability, particularly in the biomedical field.

1. Anlage, S. M. et al. "Near-field Microwave Microscopy of Materials Properties" ArXiv: cond-mat/0001075, 7 Jan, 2000

2. Wei, T. et al. "Scanning tip microwave near-field microscope" Appl. Phys. Lett., 1996. vol.68, no.24, p. 3506-8